

Packaging Technology for the ALICE Transition Radiation Detector

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Why IPE?

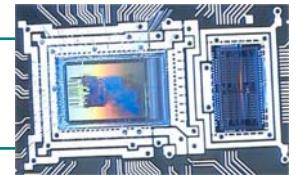
What's the task?

Where's the problem?

What we learn for packaging?

F

Forschungszentrum Karlsruhe
in der Helmholtz-Gemeinschaft



Centre for packaging since 2001

Batch production for hybrid micro-systems

160 m² gray room

SMD production line:

picker&placer,
vapour solder oven,
automatic needle tester,
tests, repair

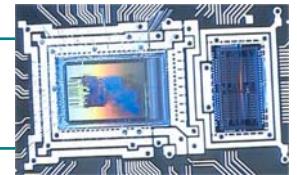
140 m² clean room

class 100 000 (measured 5000)

**... for batch production and R&D of
hybrid micro-systems (packaging):**

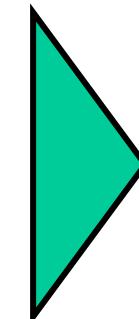
e.g. vibration sensor,
micro-spectrometer,
electronic gas sensors,
ALICE, ...





Task for transition radiation detector

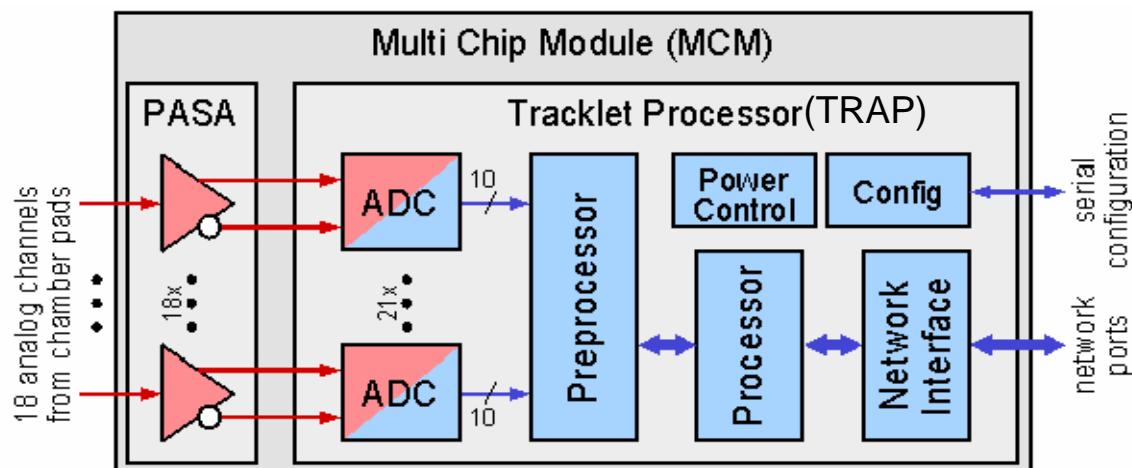
- High data rate: 15.7 TBd
- 1.2×10^6 data sources
- Tracking up to 16 000 charged particles
- Manageable connectivity -> data reduction



Chip farm at
frontend

Packaging of chips
as thin as possible

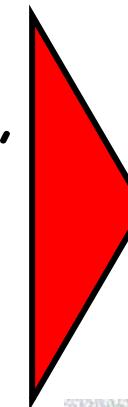
2 chips integrated in one Multi-Chip Module
serving 18 analogue channels
16 + 1 MCM's for one readout board





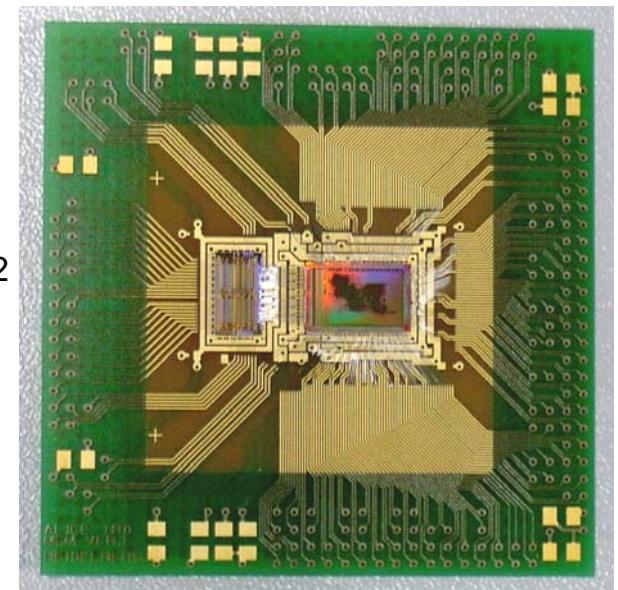
Where is the problem for packaging ???

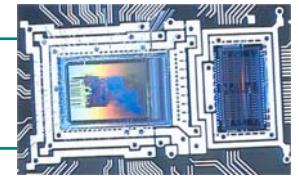
- o 65664 ball bonded MCM's
- o Each MCM with 432 balls and 460 wire bonds,
30 000 000 balls and 60 000 000 bonds
- o bonds connecting different height levels
- o very thin (<1mm) printed circuit boards
for MCM and read-out board
- o Should cost "nothing"



yield of
production
warpage

Size 41*41 mm²





Processing steps for MCM

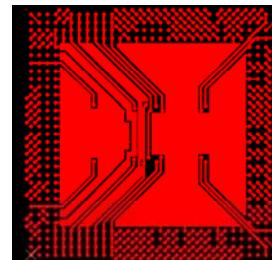
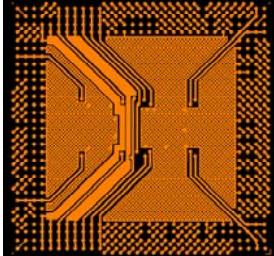
- Optimization of PCB parameters
- Die attachment
- Wire bonding
- Glob top
- Balling
- Quality control of balling
- Electr(on)ical tests of MCM's

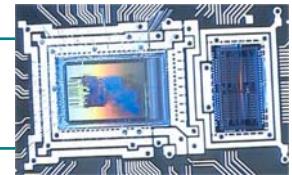


MCM: optimisation of PCB

Problem: as thin as possible and no warpage

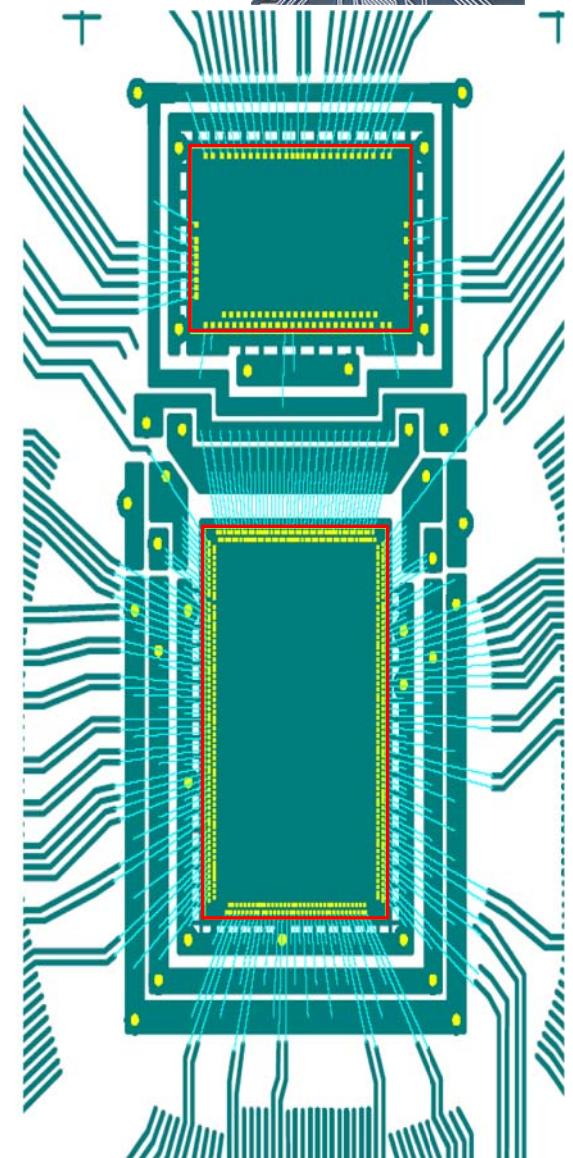
- Normal material (FR4) has glass transition temperature of $T_g \approx 120^\circ\text{C}$
- Curing the glob top needs 150°C
- Isola Duraver 117 has a $T_g > 160^\circ\text{C}$
- Tests with Boards of 0.8 and 1.0 mm thickness
- meshed and solid version of ground layer

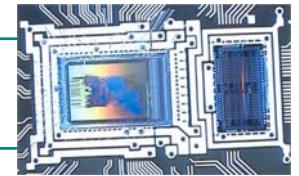




MCM: Die attachment

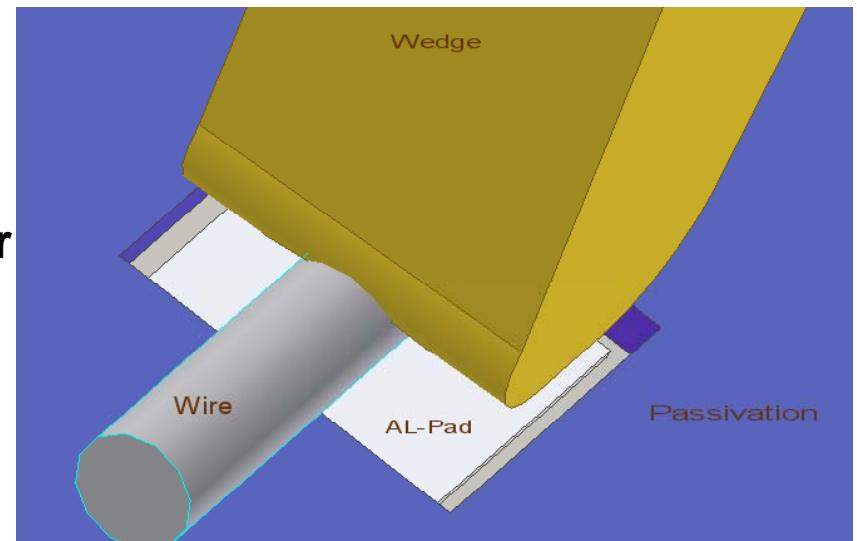
- TRAP-Chip $7.4 \times 5.0 \text{ mm}^2$
PASA-Chip $5.0 \times 3.4 \text{ mm}^2$
- Silver glue for attachment to ground
- both chips as near as possible
together for cross links
- Problems:
 - squeeze out of glue may give short circuits
 - Positioning of chips $< \pm 60 \mu\text{m}$
 - warpage by curing (**20 min at 120°C**)
- Solution (for 0.8 and 1 mm PCB):
 - Screen printing - not dispensing glue
 - Definition of a critical distance between landing of chip and next printed wire ($150 \mu\text{m}$)

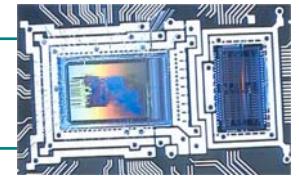




Wire bonding

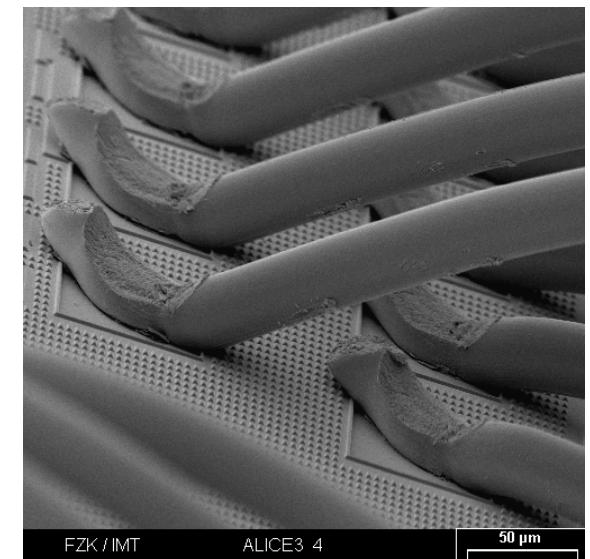
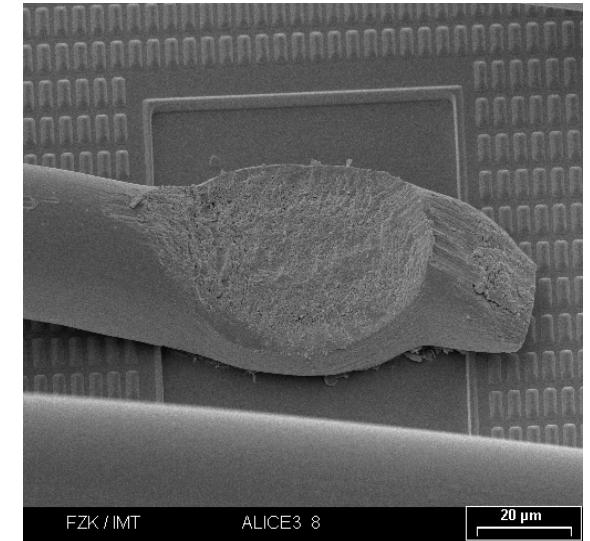
- Bond pads of the chips $70 \times 70 \mu\text{m}^2$, pitch $110 \mu\text{m}$, and staggered in 2 rows
- **Caveats:**
 - The wedge size have to fit to the size of the pad - otherwise passivation leads to poor joints
 - Position tolerance t of bond head ($t_{\text{IPE}} \approx 3\mu\text{m}$)
 - Select wire diameter w ($22.5 - 25 \mu\text{m}$)
optimal wire diameter:
 $\text{pad size} - 2 \cdot t > \text{bond length} \approx 2.4 \cdot w$
 - Tolerance of bond position may be larger at edges of bond field!!

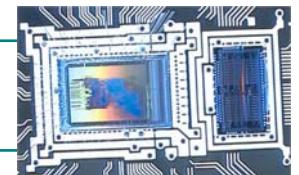




Wire bonding

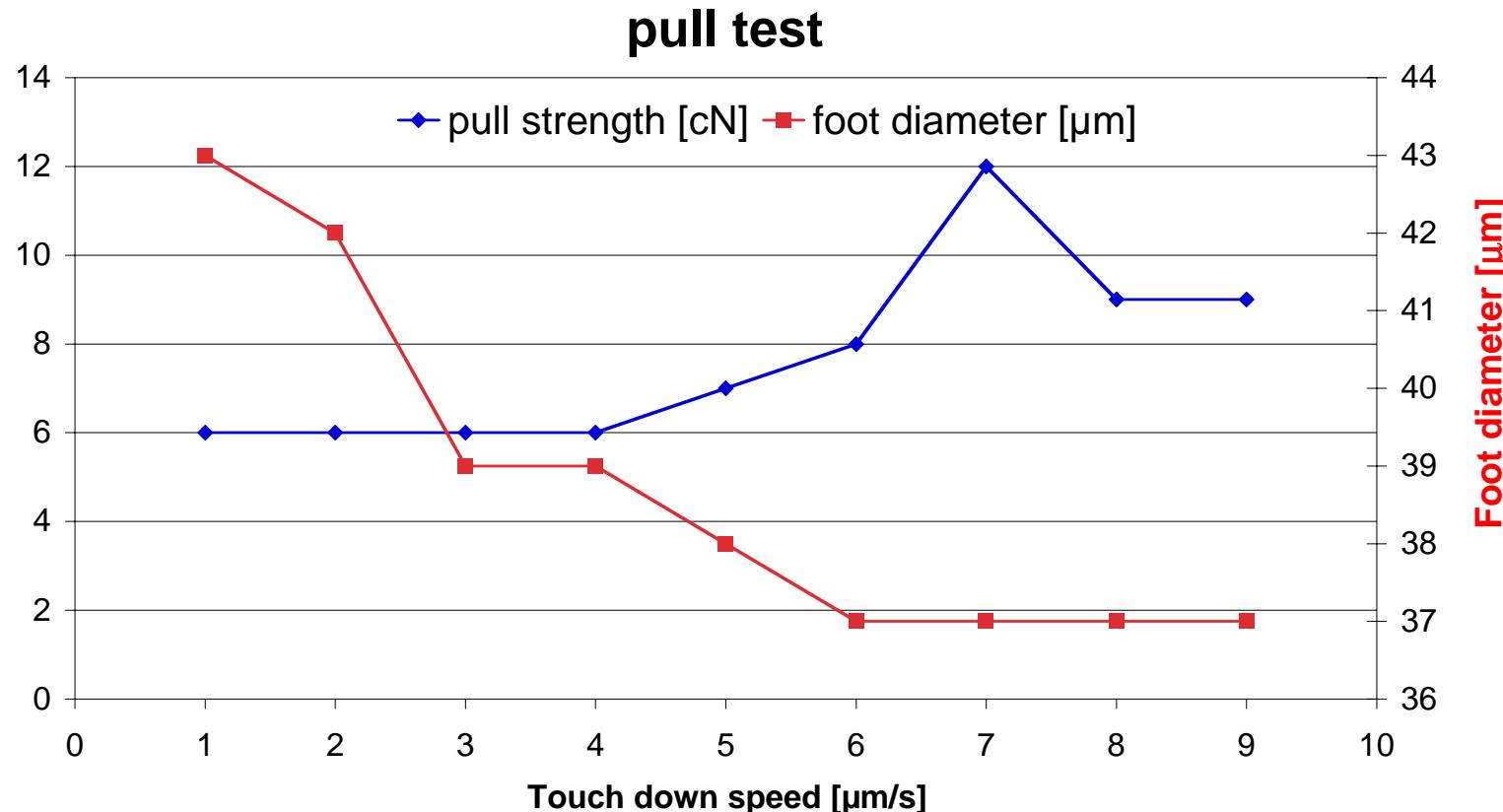
- Some typical bonds on the TRAP chip
- Also exact double row bonding
- Many more parameters define the bond process:
 - Speed of bond head at touch down
 - Used Ultra Sound power for bonding
 - Elasticity of bond pad support (PCB or Si)
 - Bond angle
 - Size of wire loop, . . .
- Especially complicated for bonds over different heights: chip - chip, chip - PCB and different materials
- Individual optimisation is necessary!
 - New bond control: measuring the bond resonance parameters and regulating the US-power!!!

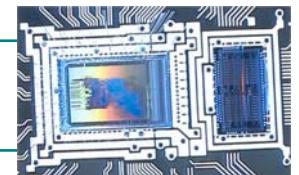




Destructive bond testing with pull tester

- bond strength for TRAP chip and 25 μm Al bonds 10 ± 2 cN

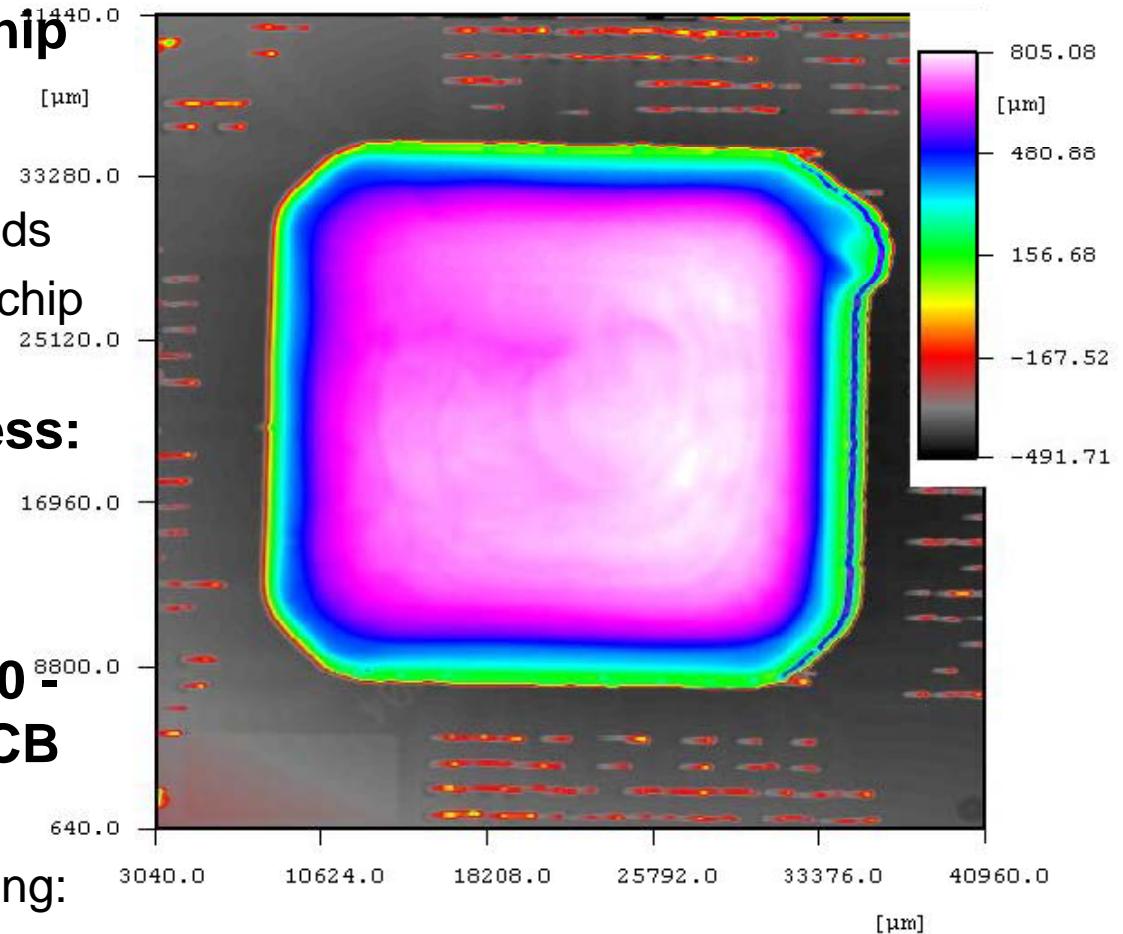


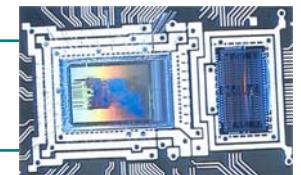


MCM: Glob Top

- **Protecting the bonds and the chip**
 - Medium coefficient of thermal expansion (80 ppm)
 - but low E-modulus protecting bonds
 - small max. particle size (pitch on chip is 110 µm)
- **Recommended minimal thickness:**

300 µm chip height +
250 µm bond loop height +
250 µm protective top layer
- **Problem warpage by curing (120 - 150 °C) -> layout changes on PCB**
 - Now warpage < 100 µm:
 - Could be compensated by soldering:
reduces height of balls by 300 µm





MCM: Balling

1. Flux (Solder Paste)

- Screen (Stencil)
- Pin transfer
- Dispenser
- Flux jet

2. Ball placement

- Gravity transfer
- Vacuum transfer
- Solder jet
- Screen paste
- Dispense paste

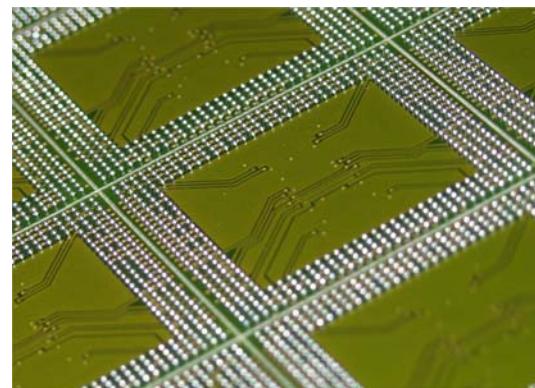
3. Inspection

- Ball count
- Location
- Quality

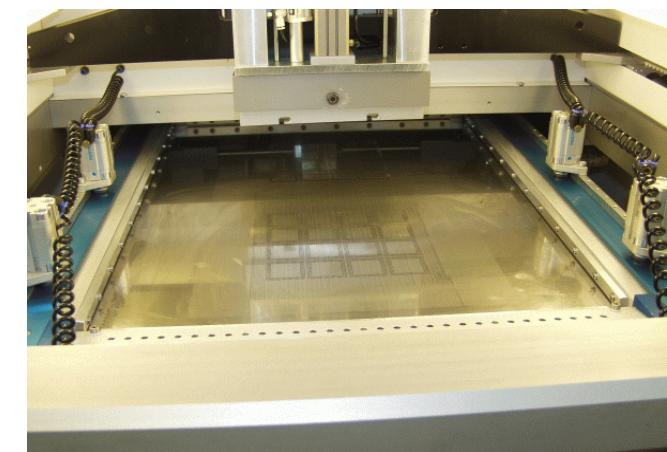
4. Reflow

- IR oven
- Vapor phase
- Forced convection

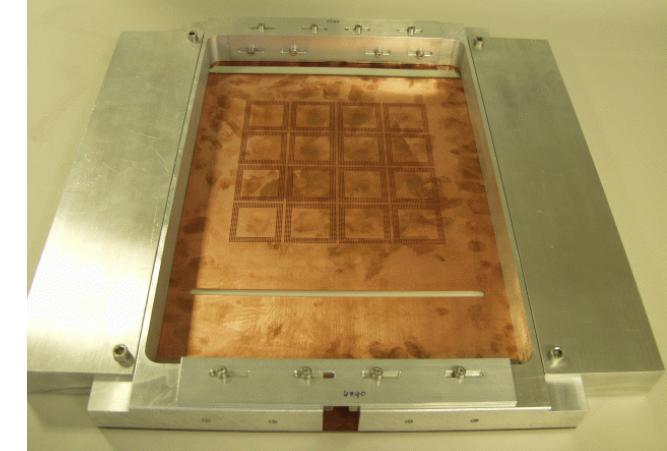
- Tested and rejected methods
- finally adopted method



432 balls per MCM,
6912 balls per substrate



Stencil
printer

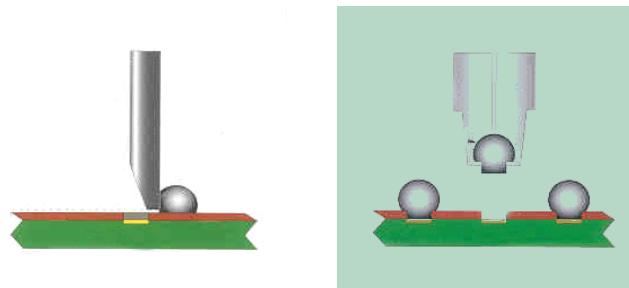


Stencil for
ball transfer

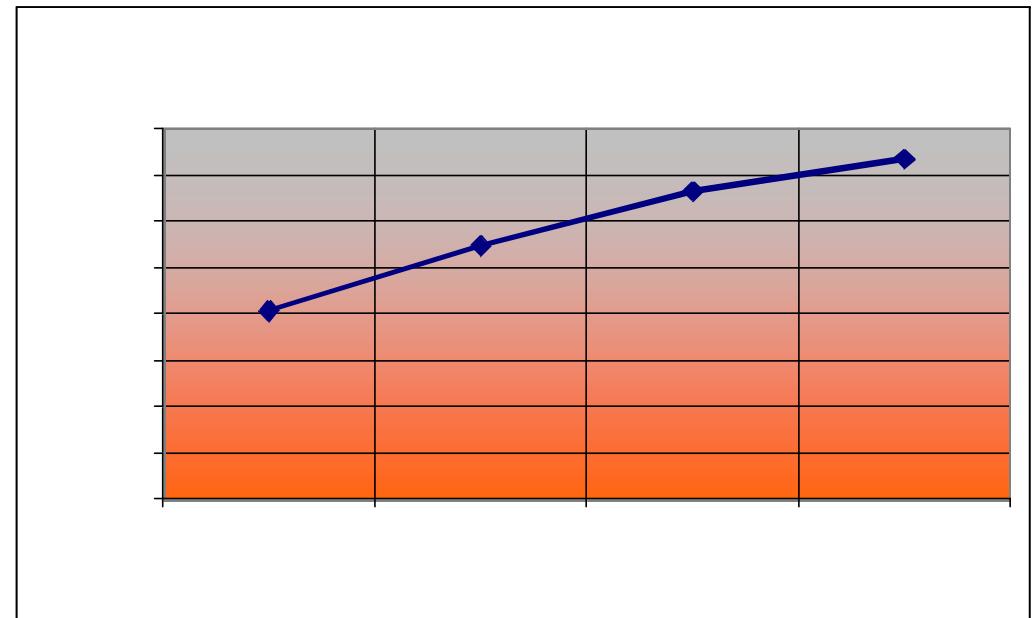


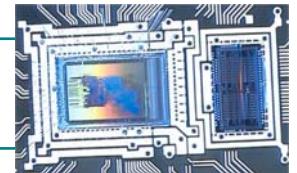
MCM: Quality test of Balling

- Problem at beginning: Low shear forces required to rip balls off

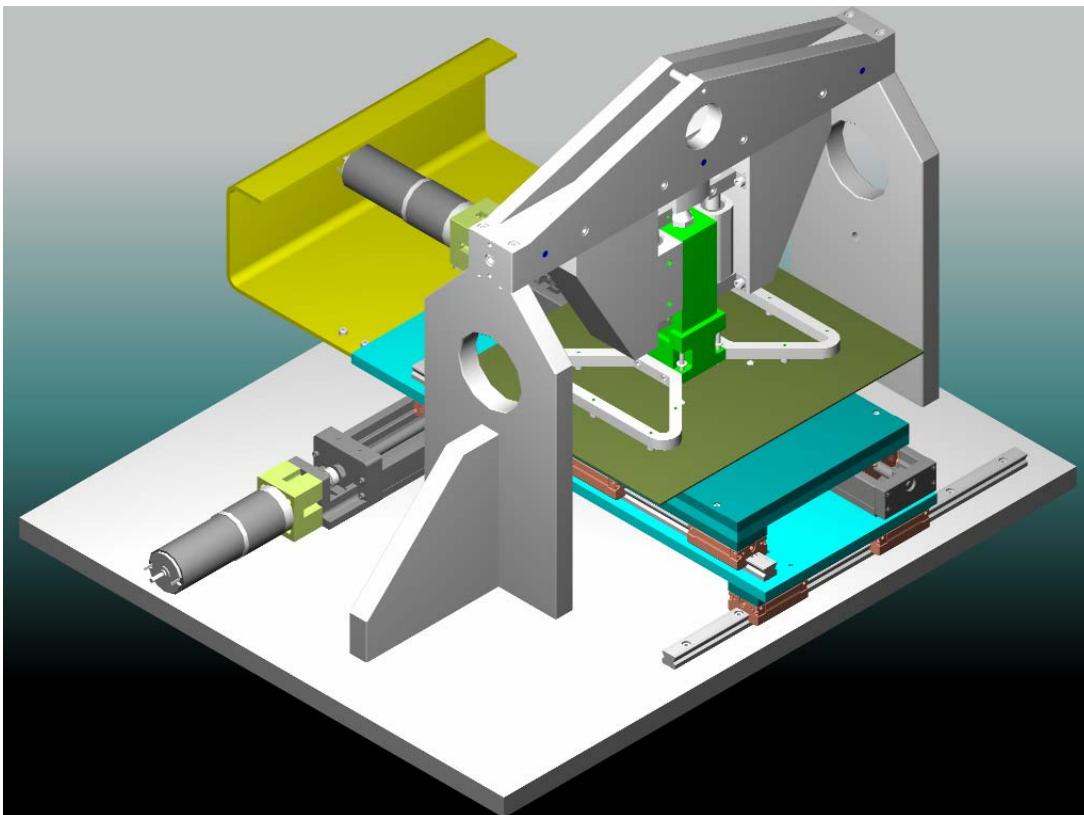


- Balls too small, new MCM and ROB layout with increased Pad Size
- solder reflow temperature profile and convection air flow !!!
(vapor oven and IR-oven not suited for balling)



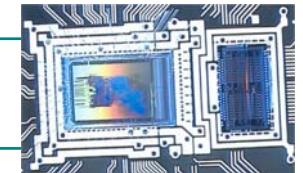


MCM electronically testing



Development of an automatic test-station (finished last week):

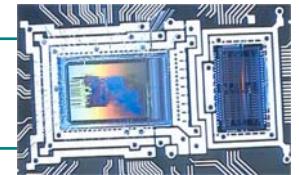
- Test of 16 MCM modules
- completely packaged
- incl. balls



Readout board

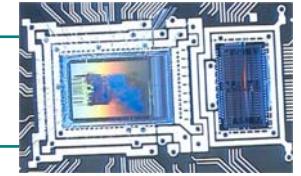
- **500 * 300 mm² and 0.8 - 1 mm thick, ev. new carbon filled PCB**
- **17 MCM's and 1000 passive components**
- **Very delicate handling**
- **Automatic quality test optically and electrically within a SPEA flying needle prober**
- **Electronic tests and burn-in tests are under preparation**

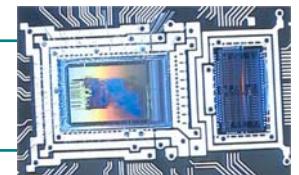




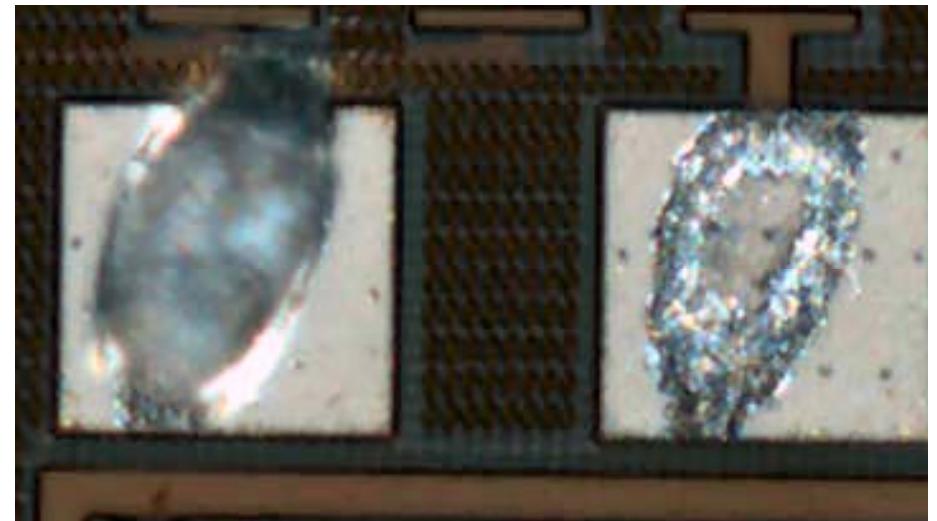
Conclusion

- **We have learned a lot - that was our intention**
 - All processes seems to be under control
 - But tests over large numbers (preproduction run) have to be done
 - Warpage was the critical question
- **Critical law of large numbers**
 - 60 000 000 bonds and 30 000 000 balls
 - What may be going wrong surely goes wrong
 - Disentangling in readout boards and MCM's helped:
Only 890 bonds and 432 balls -> good yield achievable
- **Design of packaging have normally to be started with chip design**
 - Then the job would have been easier
 - Lower number of design loops

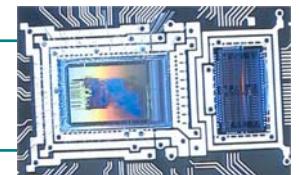




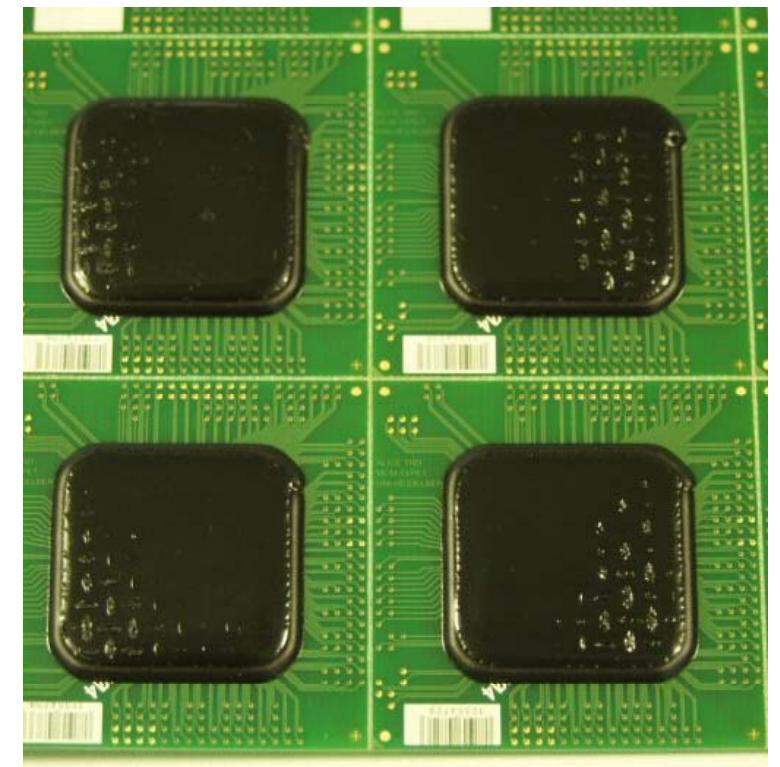
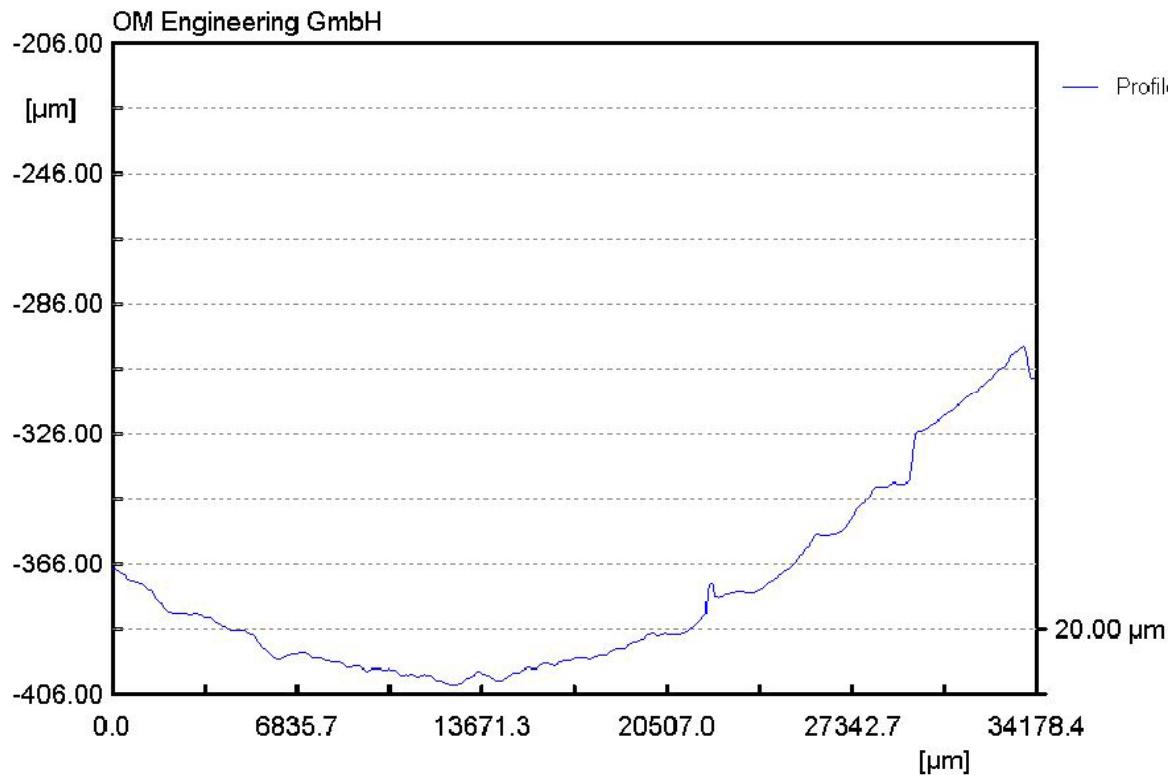
Wire bonding



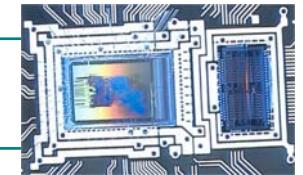
left: Footprint of an Al-bonding foot on a $70\mu\text{m}$ pad, right: welded area (removed foot). The tool used had a flat of $15\mu\text{m}$ and a front and back radius of each $25\mu\text{m}$



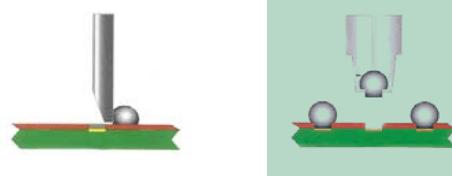
MCM: Glob Top



Warpage of MCM board by curing of glob top $\approx 100 \text{ } \mu\text{m}$



MCM Production Task: Quality control



the pull tool



pad failure,
the copper pad was torn out of the PCB